

## Electrolytic Pointing of Fine Wires

In the fabrication of point contact or pulse alloyed diodes for millimeter wavelengths, junction area restrictions require wire points with radii of the order of  $10^{-4}$  inches or less. This paper describes a device and technique for electrolytically pointing metal wires of various sizes to meet these requirements.

A technique for forming points on tungsten wires has been in existence for some time.<sup>1</sup> An extension of this was made by the development of a simple device to point tungsten and other metal wires with consistent results. The device shown in Fig. 1 consists of a container of electrolyte with a copper electrode, a pin vise and a drive mechanism for holding the whisker and a variable ac voltage supply. It has been used to form sharp points on wires from 0.001 inch to 0.007 inch diameter. The feature of this device is that it can be used for either repointing a whisker with minimum amount of material removal or cutting the whisker to length. For most materials, the etching period is controlled automatically by the action of the whisker-electrolyte interface without the need for timers or controls of any kind.

To point the whisker with minimum removal of material, it is lowered into the electrolyte, then withdrawn slowly until a maximum-height meniscus is formed. The voltage is then applied until etching is completed, as indicated by the breaking of the meniscus. When pointing a wire for the first time, two applications of this process may be necessary to change the wire end from the blunt end to a conical point.

Various materials have been pointed using the device described with a 3 to 10 N solution of KOH as an electrolyte. They include

Aluminum <sup>2</sup>	0.002 inch diameter
Aluminum—0.75 per cent Boron <sup>2</sup>	0.003 inch
Molybdenum	0.001 inch to 0.003 inch
Beryllium Copper	0.0015 inch
Phosphor Bronze	0.001 inch to 0.005 inch
Tungsten	0.001 inch to 0.007 inch
Silver Plated Tungsten	0.001 inch
Zinc	0.003 inch.

Pointing these wires takes between a second and several minutes with 3 to 6 volts, 60 cycle, applied. A few experimental trials determine the best etching voltage for the particular wire used. Typically, the resulting point radius is  $30 \times 10^{-6}$  inches with some as small as  $15 \times 10^{-6}$  inches. Fig. 2 is a microphotograph of a 0.001-inch diameter phosphor bronze wire pointed in a 7N solution of KOH.

In addition to these materials, type 302 stainless steel (0.005 inch diameter) and titanium (0.002 inch diameter) have been pointed with a higher applied voltage. An electrolyte strength of 20 N and 6 volts, for

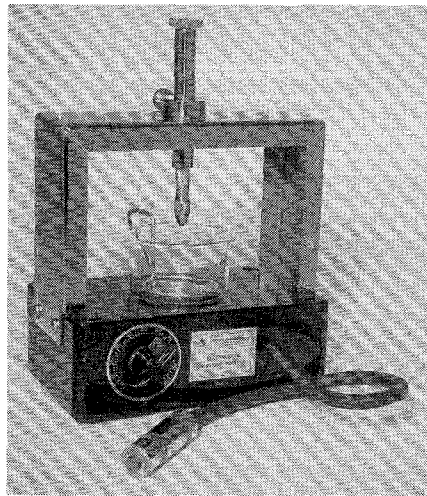


Fig. 1—Electrolytic whisker pointer.

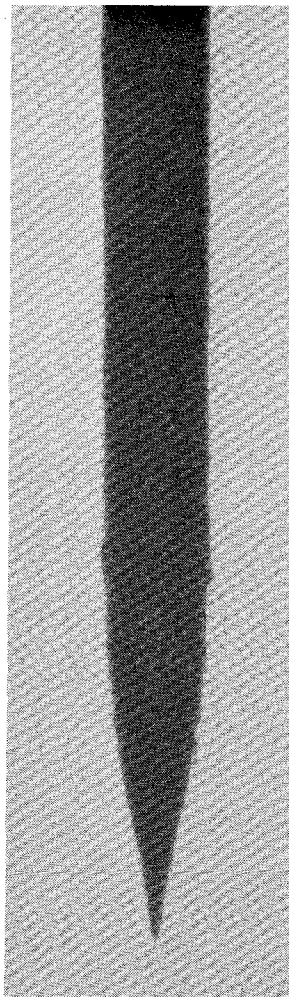


Fig. 2—Electrolytically pointed 0.001-inch diameter phosphor-bronze whisker (photographed at 563X).

example, points these wires in about 15 minutes. Platinum, 10 per cent Ruthenium (0.003 inch diameter), has been electrolytically etched by the same method, taking several hours, resulting in a point that is smooth, but more blunt than with other materials.

Nickel wire can be pointed with the same technique using a different electrolyte developed for use with gold and silver whiskers.<sup>3</sup> The solution consists of 5 per cent by weight of both potassium ferrocyanide and sodium cyanide in water. With this solution a 0.003-inch diameter nickel wire can be pointed in about a minute at 6 volts. The resulting point is quite smooth and spherical but does not have as small a radius as is obtained with most materials, being of the order of 0.002 inch.

J. W. DOZIER  
J. D. RODGERS  
Advanced Technology Corp.  
Timonium, Md.

<sup>3</sup> S. Kita, private communication.

## Analogy Between a Modulated Electron Beam in a Plasma and Transmission Lines

We shall consider a modulated electron beam passing through a plasma medium. The following assumptions shall be made in the analysis which closely follows Bloom and Peter:<sup>1</sup>

- 1) To linearize the equations, a small signal analysis is employed.
- 2) The analysis is one dimensional; motion of the particles is taken along the  $z$  axis.
- 3) Thermal motion and collisions are neglected in the plasma, where the ions are assumed stationary.

The ac quantities which vary as  $e^{j\omega t}$  are given in a coordinate system which moves with the dc velocity  $u_0$  of the electron beam. Both the dc and ac quantities are, in general, functions of  $z$ .

The equation of motion for the electron beam is

$$j\omega v_b + \frac{d}{dz}(u_0 v_b) = \eta E; \quad \eta = \frac{e}{m} \quad (1)$$

In the essentially one-dimensional beam-plasma system, we have

$$\frac{I_b}{\sigma_b} + \frac{I_p}{\sigma_p} + j\omega \epsilon_0 E = 0 \quad (2)$$

where  $\sigma_b$  and  $\sigma_p$  are, respectively, the cross sections of the electron beam and of the plasma, and  $I_b$  and  $I_p$  are the total ac currents of the beam and of the plasma, respectively.

$$\frac{I_b}{\sigma_b} = \rho_{0b} v_b + u_0 \rho_b; \quad \frac{I_0}{\sigma_0} = \rho_{0b} u_0 \quad (3)$$

$$\frac{I_p}{\sigma_p} = \rho_{0p} v_p \quad (4)$$

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<sup>1</sup> S. Bloom and R. W. Peter, "Transmission-line analog of a modulated electron beam," *RCA Rev.*, vol. 15, pp. 95-112; March, 1954.

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<sup>1</sup> W. G. Pfann, "An Electrolytic Method for Pointing Tungsten Wires," *Amer. Inst. Mining Met. Engrs.*, New York, N. Y., Tech. Publ. No. 2210, Metals Technology; June, 1947.

<sup>2</sup> Smooth regular points are not obtained with these. The point radii are typically 0.00025 inch.